RSC Advances



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Cite this: RSC Adv., 2020, 10, 17627

Received 25th February 2020 Accepted 20th April 2020

DOI: 10.1039/d0ra01787f

rsc.li/rsc-advances

1. Introduction

Humic acid (HA), a humic substance, is detectable in most environmental media, such as water, soil and sediment.¹ HA is a polyelectrolytic macromolecule with a large molecular weight; it originates from the polymerization of various biological residues during a long period.² HA causes unfavorable color changes in water, including yellow, brown, and black.³ Additionally, many organic functional groups of HA can connect with diverse organic and inorganic matter; thus, HA is difficult to remove from the environment.⁴ For example, the chelation of humic acid with heavy metal ions such as Cu²⁺, Hg²⁺, and Pb²⁺ will result in enhanced toxicity.⁵ Moreover, HA can generate a few disinfection byproducts during the chlorination of drinking water.⁶ To address these health and environmental problems, eliminating HA from water bodies is a significant research topic.

To control HA in aqueous solution, various advanced oxidation technologies (AOTs) have been widely attempted, including Fenton oxidation,^{7,8} ultraviolet (UV)-photolysis,^{9,10}

Elimination of humic acid in water: comparison of UV/PDS and UV/PMS[†]

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Humic substances are polyelectrolytic macromolecules; their presence in water leads to many environmental problems without effective treatment. In this work, the elimination of humic acid (HA), a typical humic substance, has been examined through ultraviolet (UV) activation systems in the presence of peroxydisulfate (PDS) and peroxymonosulfate (PMS), respectively. The results indicated that 92.9% and 97.1% of HA were eliminated with rate constants of 0.0328 ± 0.0006 and $0.0436 \pm 0.0011 \text{ min}^{-1}$ with 180 and 60 min treatment times at pH 6 and 3 when adding 3 and 1 mmol L⁻¹ oxidant during UV/PDS and UV/PMS, respectively; the corresponding electric energies per order were 0.0287 and 0.0131 kW h m⁻³. The HA removal was systematically investigated by varying different reaction parameters, including radical scavengers, persulphate dose, solution pH, and initial HA concentration, and by addition of various common ions. Moreover, the decomposition details were identified through the changes in the dissolved organic carbon, unique UV absorbances, and UV spectroscopic ratios. Furthermore, the destruction mechanism was verified by fluorescence spectroscopy, demonstrating that the HA structure was decomposed to small molecular fractions in the two UV/persulphate systems. In addition, the purification of HA by the two UV/persulphate processes was assessed in actual water matrices.

and catalytic ozonation.11 All these technologies depend on the function of the formed hydroxyl radical (·OH);12 however, the lifetime of \cdot OH is short (<10⁻⁴ s),^{13,14} so \cdot OH-based AOTs still have much room for improvement. Recently, sulfate radical (SO_4^{-}) -based oxidation as a newly developing AOT has been extensively researched by numerous researchers.15,16 SO4.radical is generated from the activation of peroxydisulfate (PDS) and peroxymonosulfate (PMS).17,18 Specifically, SO4. has a stronger oxidation capacity (2.5-3.1 V), which is greater than that of \cdot OH (1.8–2.7 V), and it has a longer lifetime (3–4 \times 10⁻⁵ s) than ·OH.¹⁹ Therefore, SO₄ [•] is more stable, selective, and adaptive for refractory organic removal in wastewater treatment.²⁰ SO₄^{•-} is widely employed to decontaminate many emerging pollutants in water, such as natural organic matter,^{21,22} neonicotinoid insecticides,^{23,24} typical herbicides,^{25,26} and personal care products.27,28

Current research about SO₄⁻⁻-based oxidation mainly focuses on diverse methods of activating persulphate. The usual activation methods include UV,²⁹ heat,³⁰ carbonaceous materials,³¹ metal oxides,³² and base.³³ However, thermal activation requires heating of the wastewater to over 50 °C, leading to a large amount of energy consumption. The activation efficiency of carbonaceous materials is relatively low, and their surfaces are deactivated under strong acidic conditions. Some metal cations are released into water, easily causing heavy metal pollution during metal oxide activation. Base activation is

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[†] Electronic supplementary information (ESI) available. See DOI: 10.1039/d0ra01787f

Table 1 List of abbreviations

Symbol	Definition	SI Unit
HA	Humic acid	$mmol L^{-1}$
UV	Ultraviolet	
PDS	Peroxydisulfate	mmol L^{-1}
PMS	Peroxymonosulfate	$mmol L^{-1}$
H_2O_2	Hydrogen peroxide	$mmol L^{-1}$
SO_4 ·-	Sulfate radicals	
·OH	Hydroxyl radicals	
EE/O	Electric energy per order	$kW h m^{-3}$
k	Reaction rate constant	\min^{-1}
DOC	Dissolved organic carbon	$ m mg \ L^{-1}$
SUVA	Specific UV absorbance values	a.u. L mg
3D-EEM	Three-dimensional excitation-emission matrix	
A_x	Specific absorption at one wavelength	
TBA	<i>Tert</i> -butyl alcohol	$mol \ L^{-1}$
EtOH	Ethanol	$mol L^{-1}$

were supplied by Tianjin Kemiou Reagent Corporation, China. Other analytical reagents, such as TBA, EtOH, potassium iodide, sodium hydroxide, sulfuric acid, sodium hydrogen carbonate, sodium sulfate, sodium nitrate, potassium phosphate monobasic, sodium carbonate, and sodium chloride, were supplied through Tianjin Chemical Institute, China. The solutions used in this study were prepared with deionized water.

2.2 Experimental procedures

A 100 mL beaker was used for the reactor under a UV lamp (power 16 W, wavelength 254 nm, philips Company, China). The distance between the lamp and beaker was 3 cm. A preset concentration of HA solution was prepared, and an appropriate weight of PDS or PMS was introduced into the beaker rapidly before the reaction process began. The beaker was placed on a magnetic stirrer (CJJ78-1, Shanghai Instrument Co., China) at room temperature. Then, 1 mL solution was drawn and transferred into a colorimetric tube to measure the absorbance and calculate the remaining concentration of HA. Each experiment was repeated three times. The solution pH was regulated by 0.1 mol L^{-1} NaOH and 0.1 mol L^{-1} H₂SO₄.

2.3 Analyses

The concentration of HA was measured using a spectroscopy instrument (SP-752, Shanghai Spectrum, China) at the wavelength of 254 nm. The concentrations of PDS and PMS were measured by the modified iodometric method.^{35,36} The DOC of the HA samples was detected by a total organic carbon analyzer (TOC-V, Shimadzu, Japan). The SUVA_x (a.u. L mg⁻¹) was computed by the following formula:^{37,38}

$$SUVA_x = \frac{A_x}{DOC} \times 100$$
(1)

where A_x is the specific absorption at one wavelength. A 3D-EEM fluorescence spectrophotometer (FL4500, Hitachi, Japan) was applied to investigate the HA decomposition process. The wavelengths of emission and excitation were set at 200 to 800 nm and 200 to 450 nm, respectively. The corresponding spectrum slits were fixed at 10 and 5 nm, respectively. The integral and mean times were regulated at 500 and 10 ms, respectively. The method of EE/O calculation was introduced in paragraph S1 of the ESI.[†]

3. Results and discussion

3.1 HA elimination in UV/PDS and UV/PMS

Fig. 1 illustrates the HA removal effects of the UV/PDS and UV/ PMS systems. The oxidations of PDS and PMS in dark conditions and with UV irradiation alone were implemented as the control tests. The HA removal was only 2.3% during UV irradiation after 180 min, and only 0.8% and 6.3% HA were eliminated in the inactivated PDS and PMS systems with 3 mmol L^{-1} oxidant, respectively. These results indicate that there was almost no HA degradation in the three sole systems. HA has a high molecular weight and contains various functional groups;^{39,40} therefore, it is difficult to decompose it in the

required to adjust the pH to neutral conditions, and this method usually requires coupling with other methods. Particularly, UV activation is often used due to its low pollution, low energy consumption, and ease of application. Therefore, UV activation of persulphate can be conveniently applied to degrade most organic targets in water. Additionally, PDS and PMS have diverse structures; PDS is a symmetrical molecule, and PMS is an asymmetric molecule. Furthermore, the activation mechanisms of the two persulphates are different. Although there are a few studies about UV activation of PDS for natural organic matter and HA removal,³⁴ research about UV activation of PMS for HA decomposition is rare. Moreover, few papers have been reported that systematically compare the performance of UV/PDS and UV/PMS in HA elimination, which is the innovation of this paper.

In this work, the UV/PDS and UV/PMS processes were respectively applied to eliminate HA from aqueous solution. The objectives of the comparative study are as follows: (1) examine the HA removal of the two UV/persulphate synergistic systems; (2) investigate the effects of the test parameters on the HA decomposition; (3) illustrate the function of the reactive species that are responsible for the HA decontamination; (4) study the HA elimination behavior and mechanisms based on determinations of the dissolved organic carbon (DOC), specific UV absorbance values (SUVA_x), UV spectroscopic ratios, and three-dimensional excitation-emission matrices (3D-EEM); and (5) explore the potential capability of HA removal in real water matrices (Table 1).

2. Materials and methods

2.1 Chemicals

Commercial HA was obtained from Aladdin Reagent Corporation, China; it consisted of 58.3% C, 4.2% H, and 36.1% O, and its mean molecular mass was 2485 Da. The contents of the total acidic, carboxylic and phenolic groups of the HA are 5.92, 2.62, and 3.58 mmol g^{-1} , respectively. Potassium peroxydisulfate, PMS (KHSO₅·0.5KHSO₄·0.5K₂SO₄), and hydrogen peroxide

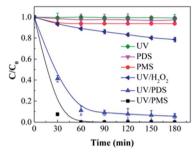


Fig. 1 HA elimination with the UV, PDS, PMS, UV/PDS, UV/PMS, and UV/H₂O₂ processes. Conditions: [HA]₀ = 15 mg L⁻¹, [PDS]₀ = [PMS]₀ = [H₂O₂]₀ = 3 mmol L⁻¹, pH₀ = 6, 3, and 4 for UV/PDS, UV/PMS, and UV/H₂O₂, respectively.

Table 2 Rate constants and economic comparison of UV/PDS and UV/PMS. Conditions: $[HA]_0 = 15 \text{ mg } L^{-1}$, $[PDS]_0 = [PMS]_0 = 3 \text{ mmol} L^{-1}$, $[pH]_0 = 6$ and 3 for UV/PDS and UV/PMS, respectively

System	UV/PS	UV/PMS
$\frac{K(\min^{-1})}{R^2}$	0.0328 ± 0.0006	0.0436 ± 0.0011
	0.98	0.97
EE/O (kW h m ⁻³)	0.0287	0.0131

control experiments. For the coupling of PDS and UV, the HA elimination reached 92.9% after 180 min. However, the HA removal was enhanced to 97.1% in UV/PMS only after 60 min, manifesting that UV/PMS was more conducive to remove HA than UV/PDS. The above results prove that UV irradiation cam effectively excite persulphates to form strong redox radicals $(SO_4^{-} \text{ and } \cdot OH, \text{ eqn } (2)-(4))^{41}$ and preferentially degrade HA in water. Additionally, the UV/H₂O₂ process was conducted as a contrasting test; the degradation ratio reached only 21.9% after 180 min treatment, which was far below than those of UV/PDS and UV/PMS.

$$S_2 O_8^{2-} \xrightarrow{hv} 2 S O_4^{\cdot-}$$
(2)

$$HSO_5^{- \xrightarrow{hv}}SO_4^{\cdot -} + \cdot OH$$
(3)

$$SO_4^{\bullet-} + \cdot OH \rightarrow SO_4^{2-} + \cdot OH$$
 (4)

$$H_2O_2 \xrightarrow{nv} 2 \cdot OH \tag{5}$$

The removal kinetics of HA by the UV/PDS and UV/PMS treatments were fitted by the first-order kinetics pattern, and the fitting results are depicted in Table 2. UV/PMS exhibited a higher rate constant (0.0436 min⁻¹) than UV/PDS (0.0328 min⁻¹). The higher efficiency and faster rate of HA removal in UV/PMS can be attributed to the influence of the acid–base properties of the solution. The values of pK_{a1} and pK_{a2} were 4 and 8 for HA, respectively.^{9,42} The initial pH value was 3 in the UV/PMS process; therefore, the HA existed in neutral form, which favors light absorption and the photochemical reaction and results in efficient decomposition.

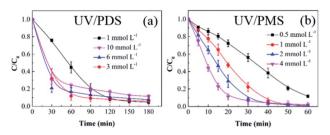


Fig. 2 Effects of the oxidant dose on HA removal in UV/PDS (a) and UV/PMS (b). Conditions: $[HA]_0 = 15 \text{ mg L}^{-1}$, $[PDS]_0 = 1-10 \text{ mmol L}^{-1}$, $[PMS]_0 = 0.5-4 \text{ mmol L}^{-1}$, $pH_0 = 6$ and 3 for UV/PDS and UV/PMS, respectively.

However, the starting pH of the PDS-added solution was 6; hence, the HA was negatively charged and had lower photochemistry activity, which is unfavorable for HA removal.

Fig. S1 in the ESI[†] shows the variations of the remaining concentrations of the two oxidants during the HA removal. It is clear that the amounts of PDS and PMS both declined with increasing treatment time, proving that the oxidants were indeed excited and transformed by disintegration to SO_4 [•] and •OH under UV radiation (eqn (2)–(4)).

The economy of UV/PDS and UV/PMS was determined through calculating the electric energy per order (EE/O),^{43–45} and the results are listed in Table 2. The definition and calculation of EE/O are introduced in detail in paragraph S1 of the ESI.† According to the data in Table 2, the EE/O of UV/PMS (0.0131 kW h m⁻³) was lower than that of UV/PDS (0.0287 kW h m⁻³), indicating that the PMS process was more cost-effective than the PDS process.

3.2 Reaction parameters

3.2.1 Persulphate dose. Based on the previous results, UV/ PMS is more efficient for HA removal than UV/PDS; therefore, the treatment time of UV/PMS was set at 60 min in the following reaction parameter investigation, and the added amount of PMS was lower than that of PDS in the cooperative systems. Fig. 2a and b show the impact of the oxidant dose on the elimination of HA in UV/PDS and UV/PMS, respectively. The PMS and PDS doses were 0.5-4 mmol L^{-1} and 1-10 mmol L^{-1} , respectively. The corresponding removal rates are presented in Table S1 of the ESI.[†] With the increase of the two oxidants (PDS 0.5-4 mmol L^{-1} and PDS 1-6 mmol L^{-1}), the HA degradation ratio and rate were both enhanced. This is because the organics degradation depends on the amounts of SO_4 .⁻ and .OH. As the persulphate dosage augmented, the generated oxidative radicals increased, which is beneficial to HA elimination. Furthermore, as shown in Table S1,† the rate constants of UV/PMS were all higher than those of UV/PDS. This is because the PMS molecule is more unstable than PDS;46 therefore, PMS can easily be activated to form active substances, leading to faster HA removal. In addition, the masking impact of the PMS dose did not occur because the added amount was not in excess. However, for the UV/PDS system, the removal was obviously suppressed at the oxidant dosage of 10 mmol L^{-1} . This may be

because the excess PDS caused a side reaction between $S_2O_8^{2-}$ and $SO_4^{\cdot-}$ to scavenge $SO_4^{\cdot-}$ radicals (eqn (6)); meanwhile, superfluous $SO_4^{\cdot-}$ would cause the reverse reaction to form $S_2O_8^{2-}$ again (eqn (6)),⁴⁷ thus reducing the degradation effect.

$$\mathrm{SO}_4^{\cdot -} + \mathrm{S}_2 \mathrm{O}_8^{\cdot -} \leftrightarrow \mathrm{S}_2 \mathrm{O}_8^{\cdot -} + \mathrm{SO}_4^{\cdot 2-}$$
 (6)

 $\mathrm{SO_4}^{\cdot -} + \mathrm{SO_4}^{\cdot -} \to \mathrm{S_2O_8}^{2-} \tag{7}$

3.2.2 Initial HA concentration. The influences of the starting HA concentration on the HA decomposition during UV/ PDS and UV/PMS are presented in Fig. 3a and b, respectively. The matching removal rate constants are listed in Table S2 of the ESI.[†] Similar to the previous results for the oxidant amount, the removal under UV/PMS was more rapid than that under UV/ PDS. Additionally, as the initial HA amount increased, the HA decomposition ratio and rate both declined in the two coupling systems. The retardation of HA elimination can be ascribed to the following underlying causes. First, at a constant persulphate dose and UV intensity, the quantity of oxidative radicals will be definite. However, with increasing organic matter concentration, the HA and its degradation byproducts will compete for SO4 '- and ·OH.11,48 Second, with increasing HA addition, the UV irradiation will be more obstructed and absorbed by the HA molecules and their decomposition intermediates, inhibiting the activation of PDS and PMS.49 Third, HA is itself a scavenger of SO_4 ⁻⁻ and OH; this, it will consume reactive radicals in increasing amounts.50,51 Thus, under the conditions of adequate oxidant, a higher HA concentration requires a longer period to reach the identical removal ratio. The above results are similar to those of many studies about organics removal by persulphate activation.52,53

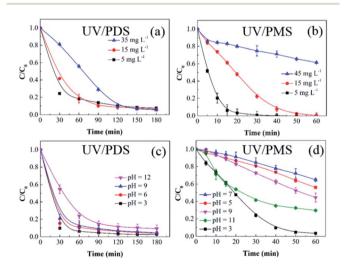


Fig. 3 Effects of the initial HA amount on HA removal in UV/PDS (a) and UV/PMS (b). Conditions: $[HA]_0 = 5-45 \text{ mg } L^{-1}$, $[PDS]_0 = 3 \text{ mmol } L^{-1}$, $[PMS]_0 = 1 \text{ mmol } L^{-1}$, $pH_0 = 6$ and 3 for UV/PDS and UV/PMS, respectively. Effects of the initial solution pH on HA removal in UV/PDS (c) and UV/PMS (d). Conditions: $[HA]_0 = 15 \text{ mg } L^{-1}$, $[PDS]_0 = 3 \text{ mmol } L^{-1}$, $[PMS]_0 = 1 \text{ mmol } L^{-1}$, $pH_0 = 3-11$.

3.2.3 Solution pH. In a persulphate oxidation simulation experiment, the pH decreased sharply to an acidic value after adding persulphate.⁵⁴ However, in practical water bodies, the pH would remain in a relatively stable range. Therefore, to avoid the influence of the buffered solution, the aqueous pH was regulated through intermittently adding 1 mol L^{-1} NaOH and 0.1 mol L^{-1} H₂SO₄ throughout the reaction process. Fig. 3c and d display the HA removal results under various solution pH conditions. For the UV/PDS system, it was observed that the HA removal dropped slightly from 97.2% to 90.7% with increasing pH from 3 to 11. As shown in Table S3,† the corresponding change in the rate constant was in accordance with the degradation effect; it declined from 0.0408 min⁻¹ at pH 3 to 0.0217 min⁻¹ at pH 11. For the UV/PMS system, the highest HA elimination ratio reached 97.1% at pH 3, followed by pH 11, 9, 5, and 7 with 67.8%, 53.5%, 42.2%, and 33.8%, respectively. Due to the strong acidic and basic conditions in the PMS addition system, the NaOH addition frequency at pH 5, 7, and 9 was higher than at pH 3 and 11, which could impact the PMS activation and then decrease the oxidation efficiency of UV/PMS. As discussed in section 2.1, under strongly acidic conditions, the form of the HA molecule will be neutral, which is helpful to eliminate HA under UV irradiation. In addition, the H⁺ would enhance the generation of $HS_2O_8^-$ with decreasing pH (eqn (8)). Then, the increasing amount of HS₂O₈⁻ can be readily decomposed to SO_4 (eqn (9)), which is beneficial to the HA degradation.55 Especially for UV/PMS, when the pH was increased from 7 to 11, the augmented OH⁻ concentration was beneficial to the PMS activation. Moreover, the molar absorption coefficient of PMS increased with increasing pH value. Therefore, the HA removal increased from 7 to 11 in UV/PMS. However, the main generated reactive species during the alkaline activation of PMS are \cdot OH, $^{1}O_{2}$, and O_{2} . ; their oxidative abilities are weaker than that of SO_4 ., leading to a reduction in the oxidizing capacity of UV/PMS. Furthermore, the annihilation between SO4. - and . OH at alkali solution would exhaust the oxidation capability of the two UV-activated persulphate processes (eqn (10)).56

$$S_2O_8^{\cdot 2-} + H^+ \to HS_2O_8^-$$
 (8)

$$HS_2O_8^- \to SO_4^{-} + SO_4^{2-} + H^+$$
 (9)

$$SO_4^{-} + \cdot OH \rightarrow HSO_5^{-}$$
 (10)

3.3 Scavenger tests

 SO_4 — and ·OH are both considered to be major reactive species during UV-activated persulphate processes; therefore, their contributions to the removal of HA were verified by radical quenching tests in the two UV/persulphate systems. Fig. 4 depicts the time-dependent degradation of HA after adding ethanol (EtOH) and *tert*-butyl alcohol (TBA) to the coupling systems, respectively. For the UV/PDS system (Fig. 4a), when the quantity of EtOH increased to 0.1 and 1.0 mol L⁻¹, the HA removal ratio declined to 40% and 32%, respectively. Additionally, when the TBA amount was enhanced to 0.1 and

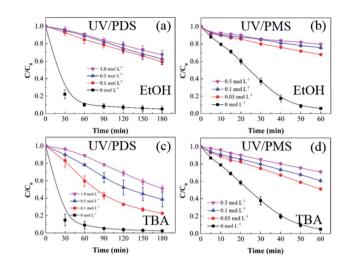


Fig. 4 Effects of radical scavengers on HA removal in UV/PDS (a and c) and UV/PMS (b and d). Conditions: $[HA]_0 = 15 \text{ mg L}^{-1}$, $[PDS]_0 = 3 \text{ mmol L}^{-1}$, $[PMS]_0 = 1 \text{ mmol L}^{-1}$, $pH_0 = 6$ and 3 for UV/PDS and UV/PMS, respectively.

1.0 mol L^{-1} , the elimination performance consistently declined to 77% and 49%, respectively (Fig. 3c). For the UV/PMS process, Fig. 4b and d exhibit similar inhibition trends with the PDS addition process; even the additions of the two scavengers were only half those added to the UV/PDS system (0.05–0.5 mol L^{-1} for EtOH and TBA in UV/PMS, respectively). When the amounts of EtOH and TBA were both enhanced to 0.5 mol L^{-1} in UV/PMS, the HA removal declined to 20.3% and 28.9%, respectively. It has been fully proven that the restraint of organic matter degradation in the UV-activated persulphate process can ne ascribed to the quenching influence on SO4 - and ·OH radicals.⁵⁷ EtOH has been widely used as a scavenger for both SO₄^{•-} and $\cdot OH$ (k_{EtOH, $\cdot _{OH}}$ = 1.8–2.8 \times 10 9 M^{-1} $s^{-1},$ $k_{\text{EtOH. SO}_{4}^{-}} = 1.6 - 7.7 \times 10^{7} \text{ M}^{-1} \text{ s}^{-1}$).⁵⁸ TBA also can be applied to quench the two radicals ($k_{TBA, -OH} = 3.8-7.6 \times 10^8 \text{ M}^{-1} \text{ s}^{-1}$, $k_{\text{TBA, SO}} = 4.0 - 9.1 \times 10^5 \text{ M}^{-1} \text{ s}^{-1}$; however, its scavenging rate for ·OH is approximately three orders greater than that for SO4^{•-.59} However, some other reactive species are generated in the homogeneous persulphate system, such as single oxygen $({}^{1}O_{2})$ and superoxide anion $(O_{2} \cdot -)$.⁶⁰ These cannot be quenched by EtOH and TBA; therefore, the HA removal was not inhibited completely under the high level of EtOH. Moreover, previous studies have suggested that SO_4 .⁻ is the primary radical in acidic conditions, while ·OH is the chief radical in alkali conditions.⁶¹ After addition of the two persulphates, the solution pH sharply decreased and became highly acidic, while the reaction continued without other adjustments. Hence, it can be deduced that SO₄^{•-} is the major reactive species in acidic conditions, and ·OH is the auxiliary species for the HA oxidization during the two synergistic processes.

3.4 HA mineralization

The transformations of the UV-Vis spectra for HA with treatment time in UV/PDS and UV/PMS are displayed in Fig. S4 of the ESI.⁺ For the two synergy systems, the UV-Vis absorptions were

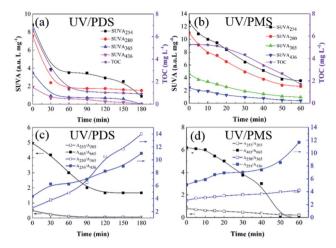


Fig. 5 Evolution of the SUVA and UV spectroscopic ratios during HA removal in UV/PDS (a and c) and UVPMS (b and d). Conditions: [HA]₀ = 15 mg L⁻¹, [PDS]₀ = 3 mmol L⁻¹, [PMS]₀ = 1 mmol L⁻¹, pH₀ = 6 and 3 for UV/PDS and UV/PMS, respectively.

both found to firmly decline with increasing reaction time. Additionally, four specific UV absorbance values (SUVA₂₅₄, SUVA₂₈₀, SUVA₃₆₅, and SUVA₄₃₆) were chosen to investigate the transformation of the molecular structure of HA during the two cooperative treatments, respectively. High SUVA254 and SUVA280 values indicate that the apparent molecular and hydrophobic structures are at high levels for organics.62 A large SUVA365 value suggests a larger molecular size of the organic molecule,9 and the SUVA436 value reflects the state of the chromophoric groups in organic matter.63 Fig. 5a and b show the variations of the various SUVA_r values with treatment time in the two synergistic systems, respectively. As the reaction progressed, all the levels of SUVA_r declined. This proves that the double bonds, chromophoric groups, and aromatic structures of the HA were destroyed, and its hydrophobicity and molecular mass also decreased during the two coupling processes. Generally, the HA transformation of SUVA_x in the PDS-added system was higher than that with added PMS, which may be due to the longer treatment time in the PDS-added process. Moreover, the DOC concentration presented a declining trend over time, and the DOC removal efficiency of UV/PDS was superior to that of UV/ PMS. These DOC elimination results also testified the above results of $SUVA_x$ changes on the other side.

Moreover, a series of UV spectroscopic values $(A_{253}/A_{203}, A_{250}/A_{365}, A_{254}/A_{436}, \text{ and } A_{465}/A_{665})$ were employed to investigate the transformations of the HA functional groups in the two synergistic systems. Normally, the A_{253}/A_{203} value corresponds to the amount of substituent groups in aromatic rings, such as carbonyl, hydroxyl and carboxylic groups; the increase of A_{250}/A_{365} indicates a reduction of the organic molecular mass, while the increase of A_{254}/A_{436} manifests the decomposition of chromophores; the decrease of the A_{465}/A_{665} ratio is attributed to a decline of the aromaticity of the organic matter.^{64,65} Fig. 5c and d present the evolutions of these UV absorption ratios during the two UV/persulphate processes, respectively. The changes in A_{253}/A_{203} and A_{465}/A_{665} both decrease over the reaction time in

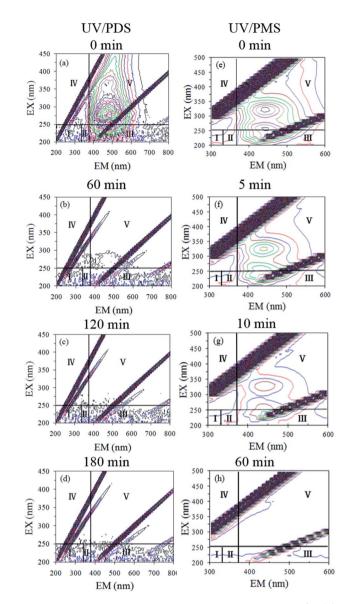


Fig. 6 3D-EEM spectra of HA at various reaction times in UV/PDS (a–d) and UV/PMS (e–h). Conditions: $[HA]_0 = 15 \text{ mg L}^{-1}$, $[PDS]_0 = 3 \text{ mmol L}^{-1}$, $[PMS]_0 = 1 \text{ mmol L}^{-1}$, $pH_0 = 6$ and 3 for UV/PDS and UV/PMS, respectively.

the two figures, which indicates that the functional groups of the HA molecules were broken during the two coupling processes. Specifically, the decreasing trend of A_{465}/A_{665} for the PMS activation process was more rapid than that of the PDS activation system, suggesting that the reactive radicals generated in UV/PMS could more easily lead to a decline in aromaticity. The levels of A_{250}/A_{365} and A_{254}/A_{436} also both augmented with increasing reaction duration, demonstrating that the two UV-activated persulphate methods could effectively destroy the chromophoric groups and reduce the molecular weight of HA.

To clarify the HA mineralization mechanism during the UV/ PDS and UV/PMS treatments in detail, the HA samples at different treatment intervals were determined by 3D-EEM fluorescence spectra (Fig. 6a–d for UV/PDS and Fig. 6e–h for UV/PMS). This fluorescence spectrum could be distributed in five areas; for instance, parts I and II are assigned to the fluorescence of aromatic proteins, region III is associated with fulvic-like fluorescence, area IV expresses the microbial byproduct fluorescence, and area V is classified as humic-like fluorescence.49,66 As can be seen in Fig. 6a and e, there was one major peak in the untreated HA sample that was predominately located in region V, indicating that the HA mainly contained the humic-like fluorophore. It was evident that the fluorescence strength disappeared gradually as the reaction progressed (Fig. 6b-d and f-h). After 180 and 60 min treatment of UV/PDS and UV/PMS, respectively, the humic-like fluorescence spectra both vanished completely, illustrating that the complex molecular structures of HA were entirely destroyed under the two coupling treatments. In addition, other minor peaks in regions I, II, and III all decreased gradually under the two UV irradiation treatments. However, the residual peaks of areas I to III for UV/PDS were more noticeable than those for UV/PMS, which manifested that small amounts of aromatic-like and fulvic-like substances were not destroyed completely and that many low molecular weight substances survived after the UV/PDS treatment. The above 3D-EEM results further prove the decomposition and mineralization of HA during the two synergistic processes.

3.5 HA removal in different water sources

Various inorganic anions are common components of the water matrix and can impact organic decontamination in water bodies. The effects of anions on the HA elimination were investigated in UV/PDS and UV/PMS, respectively; the results are presented in paragraph S2, Fig. S2 and S3 of the ESI.[†] Diverse concentrations of CO_3^{2-} , HCO_3^{-} , CI^{-} , NO_3^{-} , SO_4^{2-} , and $H_2PO_4^{-}$ were introduced to the UV/persulphate systems, respectively. Overall, the anion addition tests proved that CO_3^{2} , HCO_3^{-} , CI^{-} , and NO_3^{-} remarkably suppressed the HA removal in the two synergistic systems; SO_4^{2-} showed almost no masking effect, while $H_2PO_4^{-}$ only inhibited the HA decontamination in UV/PMS.

To further evaluate the performance of UV/PDS and UV/PMS in actual water matrices, lake water was chosen as surface water for the investigation of HA elimination. The lake water was sampled from an artificial lake on our campus. Additionally, tap water was used to conduct a control experiment to illustrate the results. The initial TOC of the surface water was 7.862 mg L^{-1} ,

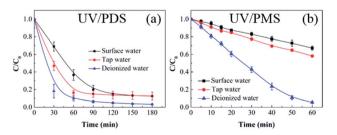


Fig. 7 HA removal from different water sources by UV/PDS (a) and UV/PMS (b). Conditions: $[HA]_0 = 15 \text{ mg L}^{-1}$, $[PDS]_0 = 3 \text{ mmol L}^{-1}$, $[PMS]_0 = 1 \text{ mmol L}^{-1}$, $pH_0 = 3.0$, 7.4, and 7.8 for deionized water, surface water, and tap water, respectively.

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and the initial TOC of tap water was 3.559 mg L^{-1} . As shown in Fig. 7, the HA removals from the lake water and tap water were lower than those from deionized water using the two coupling processes, and the removal efficiency and rate of the added PMS were obviously suppressed compared to the added PDS in the surface and tap water samples. The higher concentrations of water constituents in the two real water samples would inhibit the HA decontamination performance. Additionally, based on the aforementioned results, the inhibition impact of various inorganic anions on the HA degradation was observed in the two coupling systems, and the influence of inorganic anions on UV/PMS was larger than that on UV/PDS. This can be ascribed to the lower addition of PMS (1 mmol L^{-1}) and the shorter reaction duration (60 min) in UV/PMS. Therefore, to enhance the HA degradation in UV/PMS, a supplementary test was conducted with higher PMS addition (3 mmol L^{-1}), and the results are displayed in Fig. S5 of the ESI.† When enough oxidant was introduced into the UV activation system, the HA removals in the surface and tap water samples improved to 89.2% and 92.8%, respectively. In addition, the removal rate in the surface water was slower than that in tap water for the two synergistic systems. This is because tap water is usually treated by precipitation, filtration, and other procedures, which removes many anions from the water; therefore, the suppression effect on the HA degradation was weaker than that in the surface water.

4. Conclusions

In this work, an effective UV-activated persulphate treatment for HA removal was determined by comparing UV/PDS and UV/ PMS. The HA removal was fitted well by first-order kinetics in the experiments. The HA degradation efficiency and rate of UV/ PMS were both higher than those of UV/PDS, and the calculation of EE/O indicated that the added PMS system was more cost-efficient than the added PDS process. The HA elimination in the two coupling systems was impacted by the reaction parameters, such as the concentration of added persulphate, solution pH, initial HA concentration, and common ions. Additionally, radical scavenger experiments demonstrated that SO_4 · · · OH are both mainly responsible for HA removal in the UV/PDS and UV/PMS systems. Furthermore, the evolutions of the $SUVA_x$ and DOC values as well as the UV spectroscopic ratios manifested that the HA molecules were gradually decomposed and mineralized. The 3D-EEM fluorescence spectrum analysis confirmed that the HA was disintegrated into small molecular fractions during the two UV/persulphate processes. Lastly, the HA decomposition was tested and compared in the actual water matrices.

Conflicts of interest

There are no conflicts to declare.

Acknowledgements

The authors would like to acknowledge financial grants from the National Natural Science Foundation of China (Project No. 51908485 and 51608468), the China Postdoctoral Science Foundation (Project No. 2019T120194), and the University Science and Technology Program Project of Hebei Provincial Department of Education (Project No. QN2018258).

Notes and references

- 1 K. Okawa, Y. Nakano, W. Nishijima and M. Okada, *Chemosphere*, 2004, 57, 1231-1235.
- 2 D. Gümüş and F. Akbal, Chemosphere, 2017, 174, 218-231.
- 3 A. Zhang, W. Chen, Z. Gu, Q. Li and G. Shi, *RSC Adv.*, 2018, **8**, 33642–33651.
- 4 B. Li, I. A. Udugama, S. S. Mansouri, W. Yu, S. Baroutian,
 K. V. Gernaey and B. R. Young, *J. Cleaner Prod.*, 2019, 229, 1342–1354.
- 5 M. Zhang, J. Li, B. Li, H. Huang, N. Zhao and L. Cao, *Sci. Total Environ.*, 2020, **714**, 136839.
- 6 C. Sarangapani, P. Lu, P. Behan, P. Bourke and P. J. Cullen, *J. Ind. Eng. Chem.*, 2018, **59**, 350–361.
- 7 D. Yuan, C. Zhang, S. Tang, M. Sun, Y. Zhang, Y. Rao, Z. Wang and J. Ke, *Sci. Total Environ.*, 2020, 727, 138773.
- 8 D. Yuan, C. Zhang, S. Tang, X. Li, J. Tang, Y. Rao, Z. Wang and Q. Zhang, *Water Res.*, 2019, 114861.
- 9 G. Rao, Q. Zhang, H. Zhao, J. Chen and Y. Li, *Chem. Eng. J.*, 2016, **302**, 633–640.
- 10 S. Tang, Z. Wang, D. Yuan, Y. Zhang, J. Qi, Y. Rao, G. Lu, B. Li, K. Wang and K. Yin, *Int. J. Electrochem. Sci.*, 2020, 15, 2470–2480.
- 11 D. Imai, A. H. A. Dabwan, S. Kaneco, H. Katsumata, T. Suzuki, T. Kato and K. Ohta, *Chem. Eng. J.*, 2009, 148, 336–341.
- 12 J. Liu, J. Ke, Y. Li, B. Liu, L. Wang, H. Xiao and S. Wang, *Appl. Catal.*, *B*, 2018, **236**, 396–403.
- 13 N. Jiang, Y. Zhao, C. Qiu, K. Shang, N. Lu, J. Li, Y. Wu and Y. Zhang, *Appl. Catal.*, *B*, 2019, **259**, 118061.
- 14 J. Li, Y. Li, Z. Xiong, G. Yao and B. Lai, *Chin. Chem. Lett.*, 2019, **30**, 2139–2146.
- 15 I. A. Ike, K. G. Linden, J. D. Orbell and M. Duke, *Chem. Eng. J.*, 2018, **338**, 651–669.
- 16 X. Li, S. Tang, D. Yuan, J. Tang, C. Zhang, N. Li and Y. Rao, *Ecotoxicol. Environ. Saf.*, 2019, **177**, 77–85.
- 17 S. Tang, N. Li, D. Yuan, J. Tang, X. Li, C. Zhang and Y. Rao, *Chemosphere*, 2019, **234**, 658–667.
- 18 H. Zhang, Q. Ji, L. Lai, G. Yao and B. Lai, *Chin. Chem. Lett.*, 2019, **30**, 1129–1132.
- 19 S. Tang, D. Yuan, Y. Rao, N. Li, J. Qi, T. Cheng, Z. Sun, J. Gu and H. Huang, *Chem. Eng. J.*, 2018, 337, 446–454.
- 20 T. Zhang, Y. Liu, Y. Rao, X. Li, D. Yuan, S. Tang and Q. Zhao, *Chem. Eng. J.*, 2019, 123350.
- 21 Z. Wang, Y. Wan, P. Xie, A. Zhou, J. Ding, J. Wang, L. Zhang, S. Wang and T. C. Zhang, *Chemosphere*, 2019, 214, 136–147.
- 22 B. Shen, C. Dong, J. Ji, M. Xing and J. Zhang, *Chin. Chem. Lett.*, 2019, **30**, 2205–2210.
- 23 L. Chen, T. Cai, C. Cheng, Z. Xiong and D. Ding, *Chem. Eng.* J., 2018, 351, 1137–1146.
- 24 H. Xie, J. Zhang, D. Wang, J. Liu, L. Wang and H. Xiao, *Appl. Surf. Sci.*, 2020, **504**, 144456.

- 25 H. Chen, Z. Zhang, M. Feng, W. Liu, W. Wang, Q. Yang and Y. Hu, *Chem. Eng. J.*, 2017, **313**, 498–507.
- 26 Q. Gao, Y. Han, P. Liang and J. Meng, *Phys. Chem. Chem. Phys.*, 2020, **22**, 6291–6299.
- 27 S. Dhaka, R. Kumar, M. A. Khan, K. Paeng, M. B. Kurade, S. Kim and B. Jeon, *Chem. Eng. J.*, 2017, **321**, 11–19.
- 28 Y. Han, Q. Zhang and L. Wu, Desalination, 2020, 477, 114270.
- 29 S. Dhaka, R. Kumar, S. Lee, M. B. Kurade and B. Jeon, *J. Cleaner Prod.*, 2018, **180**, 505–513.
- 30 A. Fernandes, P. Makoś and G. Boczkaj, *J. Cleaner Prod.*, 2018, **195**, 374–384.
- 31 H. Liang, P. Hua, Y. Zhou, Z. Fu, J. Tang and J. Niu, *Chin. Chem. Lett.*, 2019, **30**, 2245–2248.
- 32 H. Li, S. Guo, K. Shin, M. S. Wong and G. Henkelman, *ACS Catal.*, 2019, **9**, 7957–7966.
- 33 O. S. Furman, A. L. Teel and R. J. Watts, *Environ. Sci. Technol.*, 2010, 44, 6423–6428.
- 34 X. Lou, D. Xiao, C. Fang, Z. Wang, J. Liu, Y. Guo and S. Lu, *Environ. Sci. Pollut. Res.*, 2016, 23, 4778–4785.
- 35 C. Liang, C. Huang, N. Mohanty and R. M. Kurakalva, *Chemosphere*, 2008, **73**, 1540–1543.
- 36 J. Wu, K. Yin, M. Li, Z. Wu, S. Xiao, H. Wang, J. A. Duan and J. He, *Nanoscale*, 2020, **12**, 4077–4084.
- 37 C. S. Uyguner and M. Bekbolet, *Catal. Today*, 2005, **101**, 267–274.
- 38 K. Wang, L. Li, Y. Lan, P. Dong and G. Xia, *Math. Probl. Eng.*, 2019, **2019**, 2614327.
- 39 S. Tang, X. Li, C. Zhang, Y. Liu, W. Zhang and D. Yuan, *Plasma Sci. Technol.*, 2019, **21**, 25504.
- 40 Q. Zhang, S. Zhang, Z. Zhao, M. Liu, X. Yin, Y. Zhou, Y. Wu and Q. Peng, *J. Cleaner Prod.*, 2020, **255**, 120297.
- 41 G. Matafonova and V. Batoev, Water Res., 2018, 132, 177-189.
- 42 M. Liu, L. Jia, Z. Zhao, Y. Han, Y. Li, Q. Peng and Q. Zhang, *Chem. Eng. J.*, 2020, **390**, 124667.
- 43 F. Rehman, M. Sayed, J. A. Khan, N. S. Shah, H. M. Khan and D. D. Dionysiou, *J. Hazard. Mater.*, 2018, 357, 506–514.
- 44 C. Duan, Y. Yu, J. Xiao, X. Zhang, L. Li, P. Yang, J. Wu and H. Xi, *Sci. China Mater.*, 2020, **63**, 667–685.
- 45 C. Duan, Y. Yu, P. Yang, X. Zhang, F. Li, L. Li and H. Xi, *Ind. Eng. Chem. Res.*, 2020, **59**, 774–782.

- 46 X. Ao and W. Liu, Chem. Eng. J., 2017, 313, 629-637.
- 47 Y. Gao, N. Gao, Y. Deng, Y. Yang and Y. Ma, *Chem. Eng. J.*, 2012, **195–196**, 248–253.
- 48 G. Xia, Y. Huang, F. Li, L. Wang, J. Pang, L. Li and K. Wang, *Front. Chem. Sci. Eng.*, 2020, DOI: 10.1007/s11705-019-1901-5.
- 49 Z. Wang, Z. Wu and S. Tang, Water Res., 2009, 43, 1533-1540.
- 50 I. A. Ike, J. D. Orbell and M. Duke, *ACS Sustainable Chem. Eng.*, 2018, **6**, 4345–4353.
- 51 K. Wang, L. Li, X. Wen, S. Zhou, Y. Lan, H. Zhang and Z. Sui, *Int. J. Electrochem. Sci.*, 2017, 8306–8314.
- 52 A. Eslami, M. Hashemi and F. Ghanbari, *J. Cleaner Prod.*, 2018, **195**, 1389–1397.
- 53 F. Ji, H. Yin, H. Zhang, Y. Zhang and B. Lai, *J. Cleaner Prod.*, 2018, **188**, 860–870.
- 54 D. An, P. Westerhoff, M. Zheng, M. Wu, Y. Yang and C. Chiu, *Water Res.*, 2015, **73**, 304–310.
- 55 A. Ghauch and A. M. Tuqan, *Chem. Eng. J.*, 2012, **183**, 162–171.
- 56 M. A. Lominchar, A. Santos, E. de Miguel and A. Romero, *Sci. Total Environ.*, 2018, 622–623, 41–48.
- 57 G. Wu, W. Qin, L. Sun, X. Yuan and D. Xia, *Chem. Eng. J.*, 2019, **360**, 115–123.
- 58 P. Xie, L. Zhang, J. Chen, J. Ding, Y. Wan, S. Wang, Z. Wang, A. Zhou and J. Ma, *Water Res.*, 2019, **149**, 169–178.
- 59 W. Liu, H. Zhang, B. Cao, K. Lin and J. Gan, *Water Res.*, 2011, 45, 1872–1878.
- 60 D. Yuan, M. Sun, S. Tang, Y. Zhang, Z. Wang, J. Qi, Y. Rao and Q. Zhang, *Chin. Chem. Lett.*, 2020, **31**, 547–550.
- 61 X. Du, Y. Zhang, I. Hussain, S. Huang and W. Huang, *Chem. Eng. J.*, 2017, **313**, 1023–1032.
- 62 Y. Li, G. Qu, L. Zhang, T. Wang, Q. Sun, D. Liang and S. Hu, *Sep. Purif. Technol.*, 2017, **180**, 36–43.
- 63 S. Valencia, J. M. Marín, G. Restrepo and F. H. Frimmel, *Sci. Total Environ.*, 2013, **442**, 207–214.
- 64 T. Wang, G. Qu, J. Ren, Q. Yan, Q. Sun, D. Liang and S. Hu, *Water Res.*, 2016, **89**, 28-38.
- 65 T. Zhang, Y. Liu, Y. Rao, X. Li and Q. Zhao, *Build. Environ.*, 2020, **175**, 106810.
- 66 T. Zhang, X. Li, Y. Rao, Y. Liu and Q. Zhao, *Sustain. Cities Soc.*, 2020, 55, 102050.